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Applicant(s): Takayoshi	Sawayama	JUL 1 9 2002 🕏		OKI.201
Serial No.	Filing Date 01/05/2001		Examiner	Group Art Unit
09/754,277	01/05/2001	RADEMARK	L. Alejandro	1731
Invention: PLASMA ET	CHING APPARATUS			
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N THE UNITED STATES PATENT AND TRADEMARK OFFICE

e Patent Application of

Takayoshi Sawayama.

Serial No.: 09/754,277

COPY OF PAPERS ORIGINALLY FILED Group Art Unit: 1731

GROUP TANK Examiner: L. Alejandro

Filed: January 5, 2001

For: PLASMA ETCHING APPARATUS

Honorable Commissioner of Patents Washington, D.C. 20231

Amendment

Sir:

In response to the Office Action mailed February 13, 2002, the following amendments and remarks are respectfully submitted in connection with the above captioned application.

Submission of Certified Copy of Priority Document

A certified copy of the priority document, Japanese patent application number 2000-225686 is submitted herewith to ensure compliance with 35 USC § 119(b). Acknowledgement of the receipt thereof is respectfully requested.

In the Specification

(1.) At page 2, line 4, please replace the paragraph that begins "When the gas-introducing plate 4..." with the following paragraph:

When the gas-introducing plate 4 lying within the processing chamber of the etching apparatus is used up, the gas-introducing plate 4 becomes thin as shown in